

What is Claimed is:

- [c1] A ring oscillator comprising an odd number of elements interconnected in a serially-connected infinite loop, each said element having an associated programmable delay.
- [c2] The ring oscillator of claim 1, further comprising:
an input to receive an input signal to start an oscillation of said ring oscillator.
- [c3] The ring oscillator of claim 1, further comprising:
an input to receive an input signal to program each said programmable delay.
- [c4] The ring oscillator of claim 1, wherein each said element comprises a non-inverting amplifier.
- [c5] The ring oscillator of claim 1, wherein said input for said programmable delay provides an adjustment of a duty factor of an output signal of said ring oscillator.
- [c6] The ring oscillator of claim 1, wherein each said element comprises at least one complementary metal oxide semiconductor (CMOS) inverter.
- [c7] The ring oscillator of claim 3, wherein said programmable delay comprises a binary word serving as a vector input.
- [c8] A circuit for testing effects of Negative Bias Temperature Instability (NBTI) on an integrated circuit, said circuit comprising: a ring oscillator according to claim 1.
- [c9] A test circuit to measure a Negative Bias Temperature Instability (NBTI) effect for PFETs (p-channel MOSFET) by stressing a target PFET component with at least one stress condition, said target PFET component being integrated as a component into said test circuit, said target PFET component having a source, a drain, and a gate, said test circuit comprising:
a ring oscillator comprising an odd number of oscillator elements interconnected serially in an infinite loop, wherein at least one said target

PFET component is integrated into said ring oscillator; and
a test output providing a point to measure at least one parameter of said
ring oscillator.

[c10] The NBTI test circuit of claim 9, wherein each said oscillator element contains at
least one said target PFET.

[c11] The NBTI test circuit of claim 9, further comprising:
a switching circuit to selectively switch said at least one stress condition
onto said target PFET.

[c12] The NBTI test circuit of claim 11, wherein said at least one stress condition
comprises at least one of:
a DC stress, wherein said target PFET receives a first constant voltage
level on said gate and a second constant voltage level on said source and
drain;
an AC stress, wherein said target PFET receives a varying voltage on said
gate; and
a free running mode, wherein said target PFET receives a varying
complementary voltage on said drain and said gate.

[c13] The NBTI test circuit of claim 11, wherein said target PFET is stressed by an AC
stress by selectively applying a gate pulse, said gate pulse being adjustable in at
least one of frequency and duty factor.

[c14] A method of testing a PFET (p-channel field effect transistor), comprising:
incorporating a target PFET into a ring oscillator having an odd number of
elements;
performing at least one stress test on said PFET; and
measuring at least one characteristic of said ring oscillator.

[c15] The method of claim 14, wherein said each said ring oscillator element contains
a variable delay.

[c16] The method of claim 14, wherein said test measurement determines an NBTI
(negative bias temperature instability) effect on at least one said target PFET.

